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TC 1700

EFS ID:

18922

Application ID:

10065277

Title of Invention:

High-Power Pulsed Magnetron

Sputtering

First Named Inventor:

Roman Chistyakov

Domestic/Foreign Application:

Domestic Application

Filing Date:

2002-09-30

Effective Receipt Date:

2002-10-16

Submission Type:

Information Disclosure Statement

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null

Confirmation Number:

5690

Attorney Docket Number:

ZON-001

2011-001

Digital Certificate Holder:

cn=Kurt Rauschenbach, ou=Registered Attorneys, ou=Patent and Trademark Office, ou=Department of Commerce, o=U.S.

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Application Number:

10/065,277

Stylesheet Version: 1.0

Disclosure Statement

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Submission Type: Information

TC 1700

Number:

High-Power Pulsed Magnetron Sputtering

First Named Inventor: Mr. Roman Chistyakov

SUBMITTED BY

Name:

Dr. Kurt Rauschenbach

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40,137

Electronic Signature Mark: kr

Date Signed: 20021016

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Attached Files:

us-information-disclosure-statement

zon-001-idsids.xml

Comments:

Electronic Information Disclosure Statement



High-Power Pulsed Magnetron Sputtering REC

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Application:

Confirmation:

5690

Applicant(s):

Roman Chistyakov

Docket

ZON-001

Number:

Group Art Unit: 1753

Examiner:

Unassigned

search string:

(5015493 or 6296742 or 6413382 or 6436251 or 5875207 or 4953174 or 6296742 or

4965248).pn.

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

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Signature

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